



IPW

AMENDMENT TRANSMITTAL LETTER				Docket No. ISH-0234	
Application No. 10/543,166-Conf. #7946		Filing Date July 22, 2005		Examiner A. Aboulfaida	
				Art Unit 2891	
Applicant(s): Hideki YAMANAKA et al.					
Invention: SILICON SEMICONDUCTOR SUBSTRATE AND METHOD FOR MANUFACTURING THE SAME					
TO THE COMMISSIONER FOR PATENTS					
Transmitted herewith is an amendment in the above-identified application.					
The fee has been calculated and is transmitted as shown below.					
CLAIMS AS AMENDED					
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate	
Total Claims	18	- 20 =	0	x 50.00	0.00
Independent Claims	2	- 3 =	0	x 210.00	0.00
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>					0.00
Other fee (please specify):					
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:					0.00
<input checked="" type="checkbox"/> Large Entity <input type="checkbox"/> Small Entity					
<input type="checkbox"/> No additional fee is required for this amendment.					
<input checked="" type="checkbox"/> Please charge Deposit Account No. <u>18-0013</u> in the amount of \$ _____ A duplicate copy of this sheet is enclosed.					
<input type="checkbox"/> A check in the amount of \$ _____ to cover the filing fee is enclosed.					
<input type="checkbox"/> Payment by credit card. Form PTO-2038 is attached.					
<input checked="" type="checkbox"/> The Director is hereby authorized to charge and credit Deposit Account No. <u>18-0013</u> as described below. A duplicate copy of this sheet is enclosed.					
<input checked="" type="checkbox"/> Credit any overpayment.					
<input checked="" type="checkbox"/> Charge any additional filing or application processing fees required under 37 CFR 1.16 and 1.17.					
 Carl Schaukowitch Attorney/Agent Reg. No.: 29,211				Dated: <u>January 2, 2008</u>	
RADER, FISHMAN & GRAUER PLLC 1233 20th Street, N.W. Suite 501 Washington, DC 20036 (202) 955-3750					



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Patent Application of:
Hideki Yamanaka et al.

Attorney Docket No. ISH-0234

Application No.: 10/543,166

Confirmation No.: 7946

Filed: July 22, 2005

Art Unit: 2891

Examiner: A. Aboulfaida

For: SILICON SEMICONDUCTOR
SUBSTRATE AND METHOD FOR
MANUFACTURING THE SAME

AMENDMENT UNDER 37 C.F.R. §1.111

Mail Stop Amendment

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

I. INTRODUCTORY COMMENTS

In response to the Office Action dated October 5, 2007, please amend the above-identified application as set forth below.

Claims 1-11 are pending in the application. By this Amendment, claims 1 and 4-6 are amended and claim 11 is added.

II. AMENDMENTS TO THE DRAWINGS

(There are no amendments to the drawings)

III. AMENDMENTS TO THE SPECIFICATION

(There are no amendments to the specification)